



2812
JFLW

In Re Application of:

Bao et al.

Serial No.: 10/618,527

Filed: July 11, 2003

**For: Semiconductor Device And Method
For Preventing Damage To Anti-Reflective
Structure During Removing An Overlying
Photoresist Layer**

Group Art Unit: 2812

Examiner: Guerrero, Maria F.

Confirmation No.: 5054

TKHR Docket: 252011-1510

Top-Team Ref. 0503-9677US

Certificate of Mailing

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail, postage prepaid, in an envelope addressed to: Mail Stop Amendment; Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450, on May 13, 2004.

H. Ch Shill

Signature – Hui Chin Barnhill

AMENDMENT AND RESPONSE TO OFFICE ACTION

Mail Stop Non-Fee Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

The Office Action mailed March 2, 2004, has been carefully considered. In response thereto, please enter the following amendments and consider the following remarks.